

Amendments to the Claims:

The following listing of claims will replace all prior versions, and listings, of claims in the application:

1-9. (Canceled)

10. (Currently Amended) A method for manufacturing a metal master comprising the steps of:

forming a conductive film by an electroless plating method on a glass master having fine depressions and protrusions for forming an information recording region of an information recording disc;

forming an electrolytic plating layer by an electrolytic plating method on the conductive film; and

removing the conductive film and the electrolytic plating layer from the glass master to provide a metal master;

wherein the conductive film is formed to have a thickness greater than a step height of the fine depressions and protrusions of the glass master, the step height of the fine depressions and protrusions is 30nm or less and the thickness of the conductive film is 40nm to 200nm.

11. (Currently Amended) A metal master comprising a conductive film having copied fine depressions and protrusions for forming an information recording region of an information recording disc, and an electrolytic plating layer formed on the conductive film, wherein the conductive film has a thickness ~~in the range of 35 to 200 nm and is greater than a~~ step height of the fine depressions and protrusions, the step height of the fine depressions and protrusions is 30nm or less and the thickness of the conductive film is 40nm to 200nm.

12-19. (Canceled)